

# Numerical advances in Self-Consistent Field Theory simulations of Block Copolymers

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IPAM, UCLA, 2013

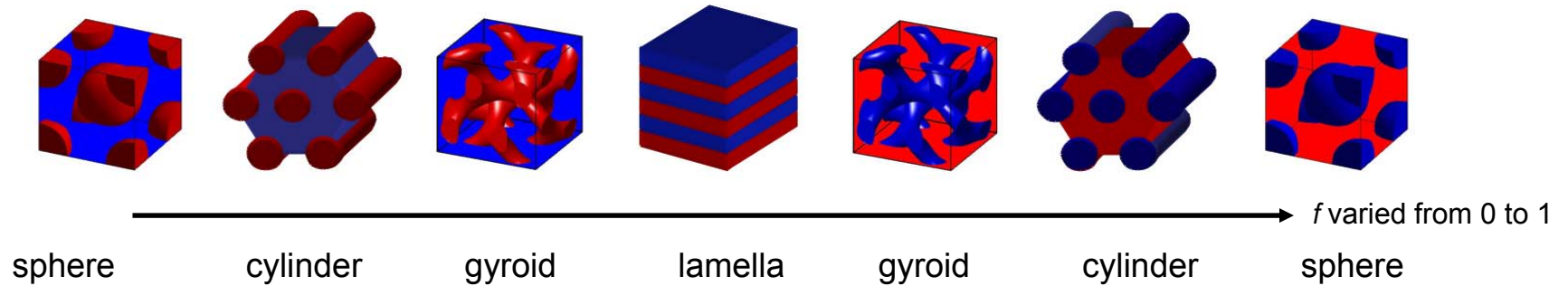
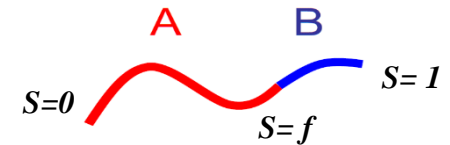
# Collaborators

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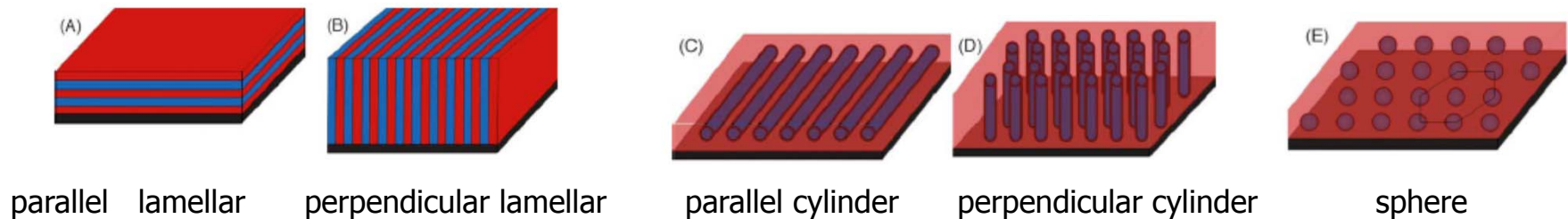
- Hector D. Cenicerros, Mathematics, UCSB
- Kris Delaney, MRL, UCSB
- Glenn H. Fredrickson, MRL, UCSB
- Edward Kramer, Materials, UCSB
  
- Su-Mi Hur, Chemical Eng., U. Wisconsin-Madison
- Tanya Chantawansri, Army Research Lab, Maryland
- **Sean Paradiso**, Chemical Eng., UCSB
- Per Von Soosten, Mathematics, UCSB

# Block Copolymer Lithography

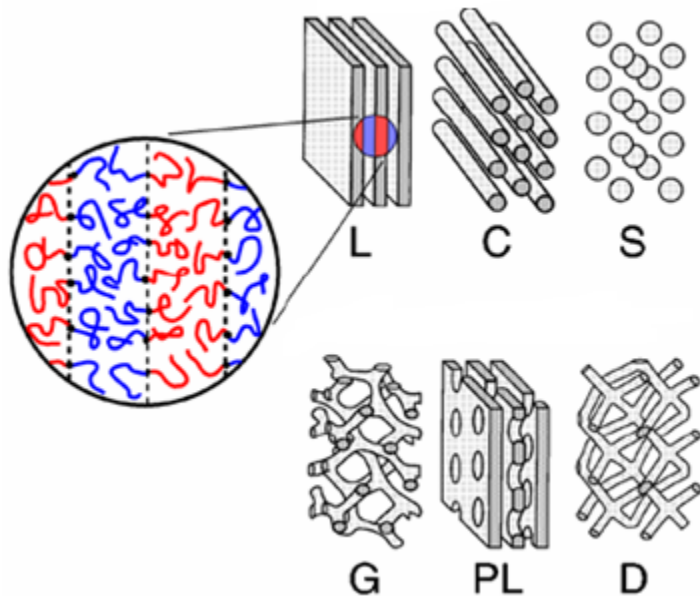
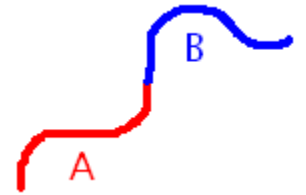
- Thermodynamic incompatibility & chemical bonding  
 → microscopic phase separation



- Self-assembly of block copolymer thin films: a promising high resolution, next generation lithographic tool



# Bulk Phases of Diblock Copolymers



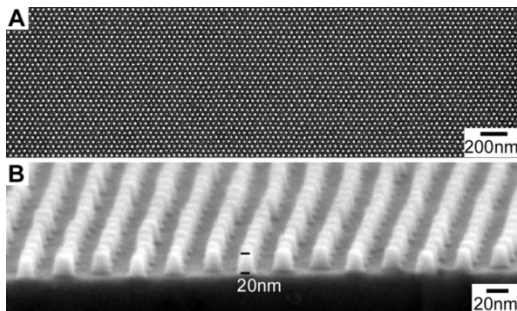
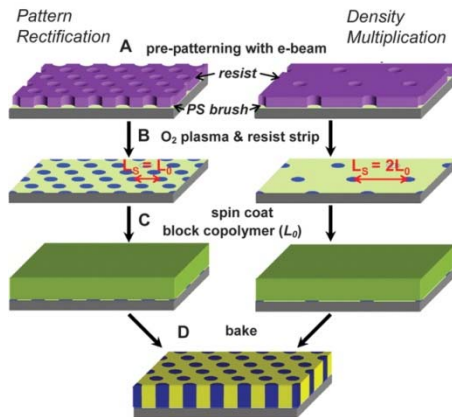
- In 3D we can see 6 bulk phases
  - L: Lamellar
  - C: Cylindrical
  - S: Spherical
  - G: Gyroid
  - PL: Perforated-lamellar
  - D: Double Diamond
- In 2D we can only see 2 of these phases
  - L: Lamellar
  - C: Cylindrical

M.W. Matsen, *J. Physics: Condens. Matter*. 2002, 14, R21-R47

# Directed Self-Assembly

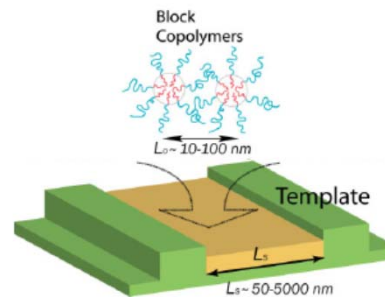
- Long range dimensional control – removal of defects and grain boundaries
- Placement accuracy: satisfying alignment and registration tolerances

## Chemically Patterned Substrate

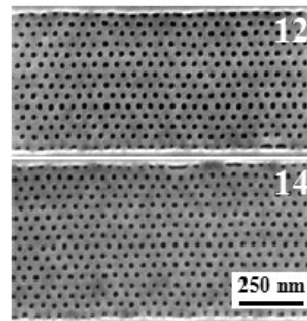


R. Ruiz et al. *Science* 2008, 321(5891), 936

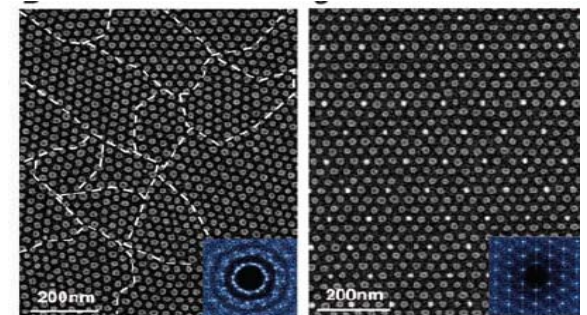
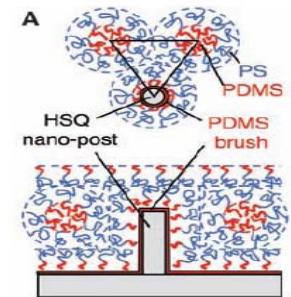
## Topographically Patterned Substrate (graphoepitaxy)



Joy Y. Cheng et al. *Adv. Mater.* 18, 2505 (2006)



S. Xiao et al. *Nanotechnology*, 16, S324 (2005)

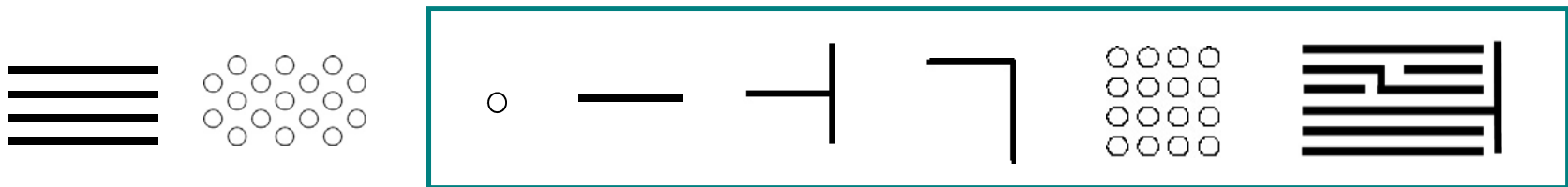


Ion Bitá, et al. *Science* 321, 939 (2008) 5

# Requirements for Block Copolymer Lithography

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- Improved long range dimensional control
- Placement accuracy: satisfying alignment and registration tolerances
- Improved resolution and linear density - beyond the 10 nm?
- Basis set of essential features

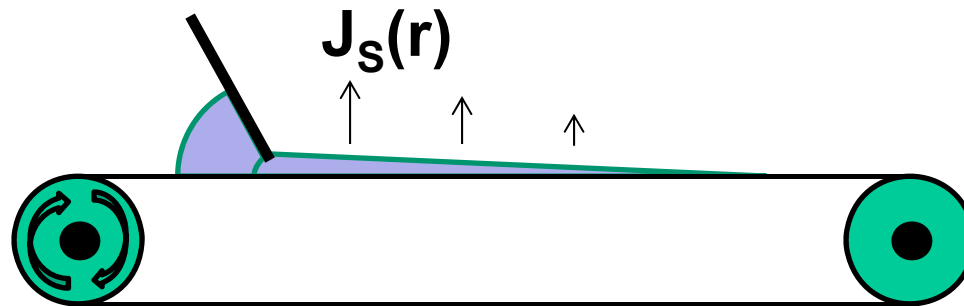


Non-natural structures

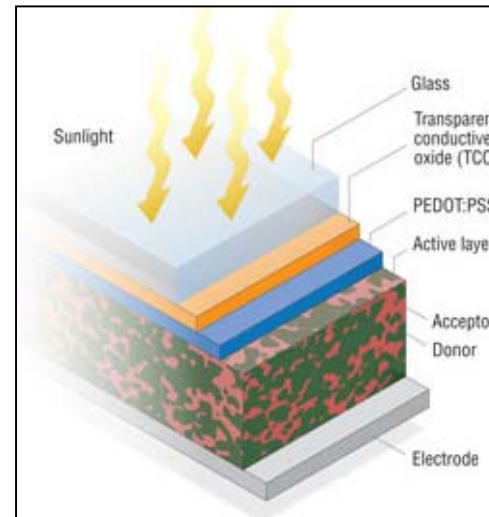
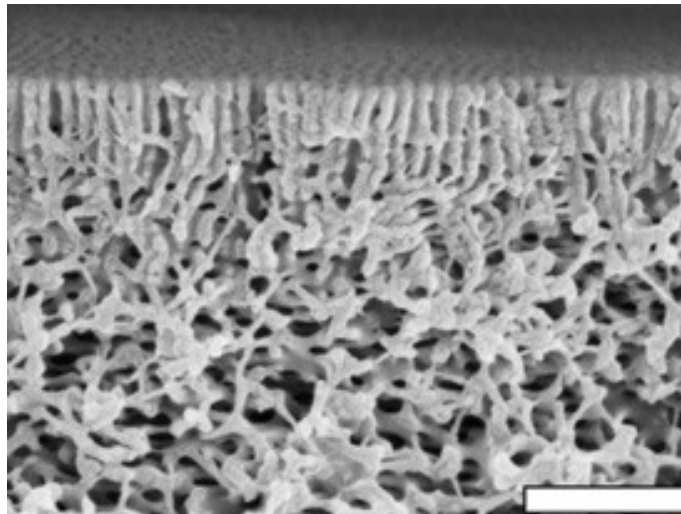
- Features with multiple sizes and pitches in the same layer
- Satisfying pattern transfer requirements and integration
- Enhanced process window
- Achieving throughput requirements, either via single wafer or batch processing: average net throughput of ~1 wafer per 1-2 minutes

# Evaporation Dynamics

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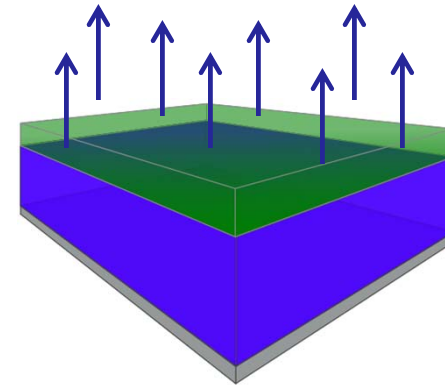
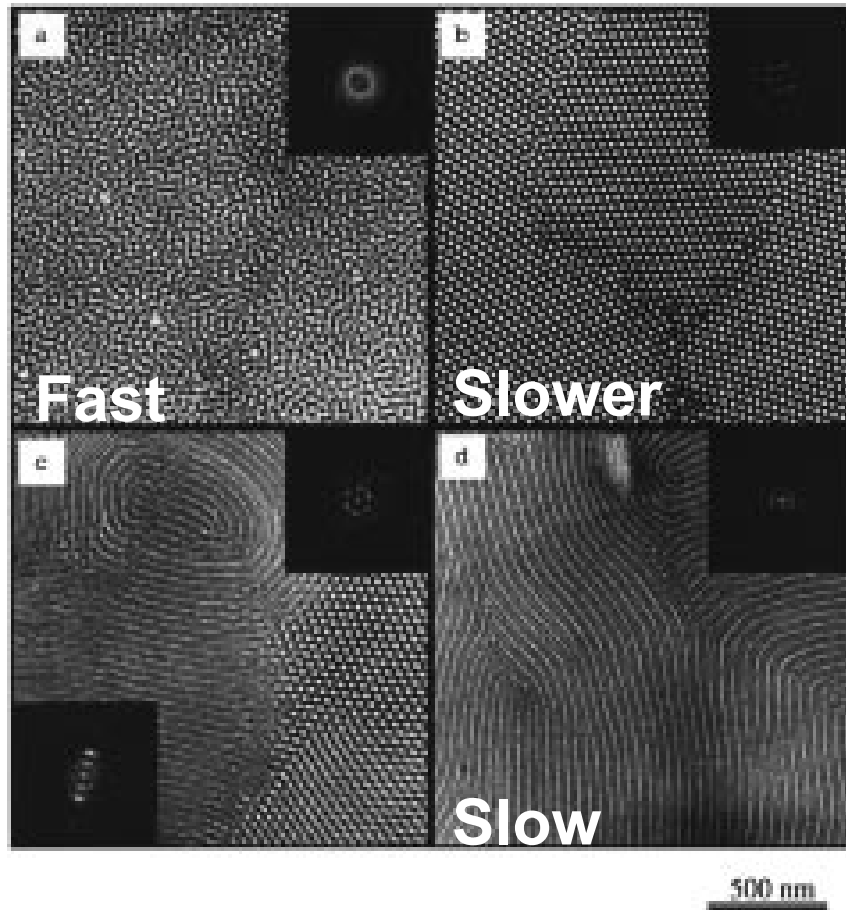
[http://www1.eere.energy.gov/solar/sunshot/pv\\_organic.html](http://www1.eere.energy.gov/solar/sunshot/pv_organic.html)



Peinemann, Abetz, Simon, *Nature Materials*, **6**, 992-996 (2007)

# Pattern Selection via Controlled Evaporation

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Kim, G., & Libera, M. (1998). Morphological development in solvent-cast polystyrene-polybutadiene-polystyrene (SBS) triblock copolymer thin films. *Macromolecules*, 31(8), 2569–2577. doi:10.1021/ma971349i

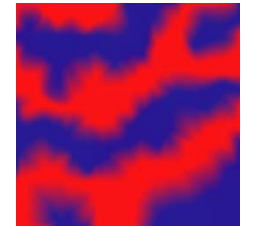
# Self-Consistent Field Theory (SCFT)



- Particle based model: many Gaussian chains interacting with each other ( $\sim$  Wiener Process)

$$Z = \int \mathcal{D}\mathbf{r} \exp(-\beta U[\mathbf{r}]) \quad U[\mathbf{r}] : \text{potential energy}$$

## Hubbard-Stratonovich Transformation



- Fi  $Z = \int \mathcal{D}w \exp(-H[w]) \quad H[w] = C \int_V d\mathbf{x} h(w) - n \ln Q[w]$

$H[w]$  : effective Hamiltonian (energy functional of field  $w$ )

$C$  : coordination number (dimensionless chain concentration)

$Q[w]$  : a single chain partition function in an external field  $w$

- Mean field approximation: single configuration dominates the partition

$$\left[ Z = \int \mathcal{D}w \exp(-H[w]) \right] \xrightarrow{\infty} Z \approx \exp(-H[w^*]) \quad \beta A = -\ln Z \approx H[w^*]$$

# Self-Consistent Field Theory

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- Single-chain partition function  $Q$

$$Q[w] = \frac{1}{V} \int_V E_{\mathbf{x}} \left[ \exp \left\{ - \int_0^1 w(X_s) ds \right\} \right] d\mathbf{x}$$

- Energy functional  $H[w]$  and density operators can be evaluated from chain propagator  $q(\mathbf{x}, s; [w])$  (**Feynman-Kac**)   $q(\mathbf{x}, s; [w])$

$$Q[w] = \frac{1}{V} \int_V q(\mathbf{x}, 1) d\mathbf{x}$$

$$\frac{\partial}{\partial s} q(\mathbf{x}, s; [w]) = \Delta q(\mathbf{x}, s; [w]) - w(\mathbf{x})q(\mathbf{x}, s; [w]),$$

$$q(\mathbf{x}, 0; [w]) = 1, \text{ plus b.c.}$$

E. Helfand, *J. Chem. Phys.* 62, 999-1005 (1975)

M.W. Matsen, M. Schick, *Phys. Rev. Lett.* 72, 2660-2663 (1994)

# SCFT Equations

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- Effective Hamiltonian:

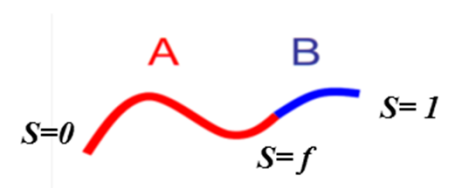
$$H[W, \Sigma] = \int_V \left( (1 - 2f)W - \Sigma + \frac{1}{\chi_N} W^2 \right) dx - V \ln Q[W, \Sigma],$$

where

$$Q[W, \Sigma] = \frac{1}{V} \int_V q(x, 1) dx,$$

and  $q$  satisfies the diffusion equation

$$\begin{aligned} \frac{\partial q}{\partial s} &= \Delta q - \psi q, & x \in V, & s \in (0, 1), \\ q(x, 0) &= 1. \end{aligned}$$



We have defined

$$\psi = \begin{cases} \Sigma - W, & 0 \leq s \leq f, \\ \Sigma + W, & f < s \leq 1. \end{cases}$$

# SCFT Equations – Gradient Flow

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- Dynamics:

- Mean field (saddle point) solution (SCFT)
- Solving for Q and densities: most numerically expensive step.

$$\frac{\partial W}{\partial t} = \phi_A(x; W, \Sigma) - \phi_B(x; W, \Sigma) + 1 - 2f - \frac{1}{\chi_N} W,$$

$$\frac{\partial \Sigma}{\partial t} = \phi_A(x; W, \Sigma) + \phi_B(x; W, \Sigma) - 1,$$

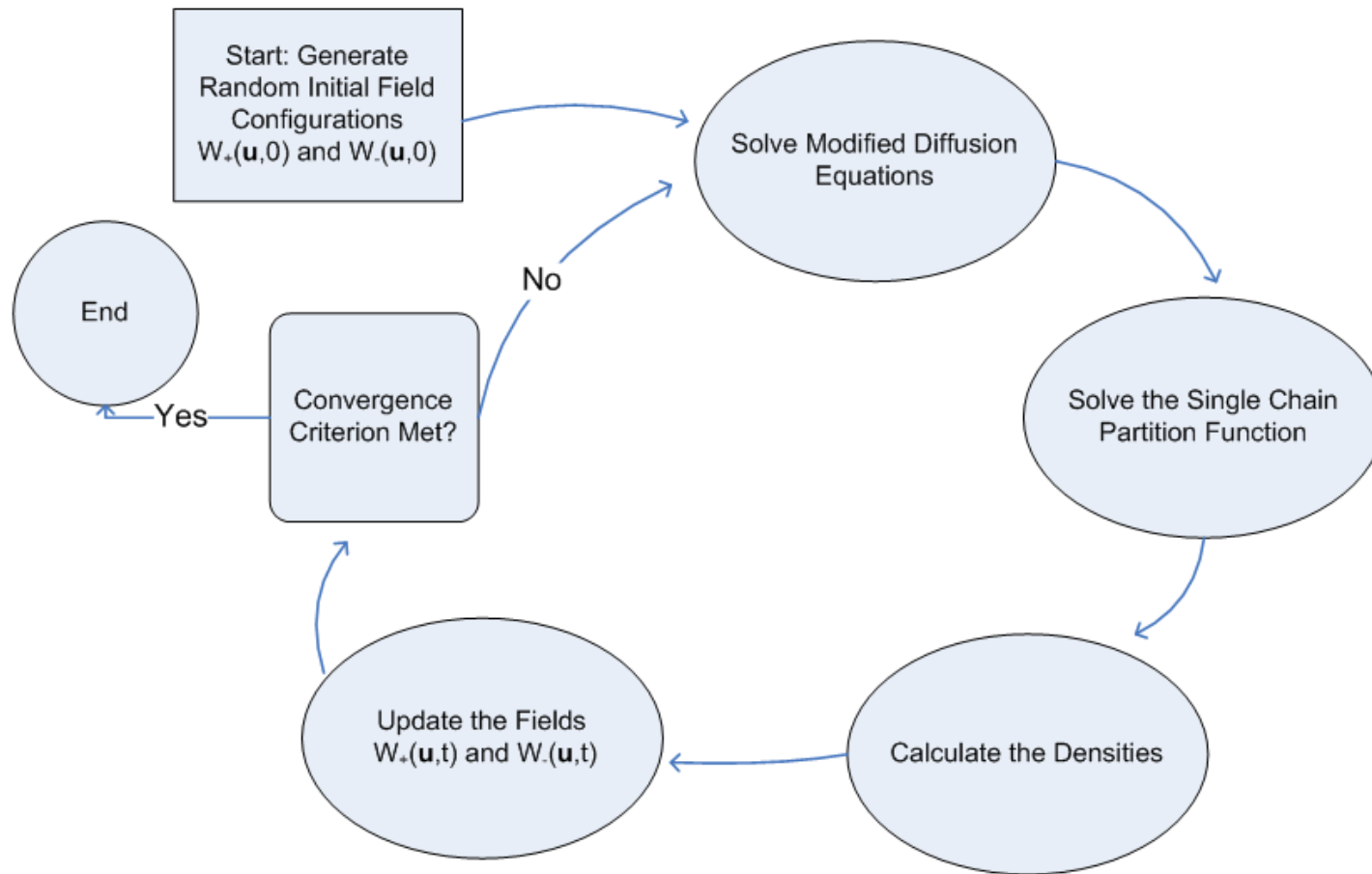
$$\phi_A(x; W, \Sigma) = \frac{1}{Q} \int_0^f q(x, s) q^\dagger(x, 1 - s) ds,$$

$$\phi_B(x; W, \Sigma) = \frac{1}{Q} \int_f^1 q(x, s) q^\dagger(x, 1 - s) ds,$$

$$Q = \frac{1}{V} \int_V q(x, 1) dx.$$

# Basic Schematic

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# Existence of Solutions

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- Dynamics equations: ODE in a Banach space.

$$\frac{dy}{dt} = F(y); \quad F : (L^p(V))^2 \rightarrow (L^p(V))^2, \quad p \geq \frac{3}{2}$$

- F is Lipschitz: Follows from Kato-Rellich + semigroup estimates:

$$q(s) = e^{s(\Delta-\psi)} q_0$$

- F is in fact Fréchet differentiable:

$$q(s) = e^{s\Delta} q_0 - \int_0^s s^{(s-t)\Delta} \psi e^{t\Delta} q_0 dt + O(\|\psi\|^2)$$

- Picard's theorem: (Local) Existence and Uniqueness.
- Global existence: Extension of local solutions.

# Phase separation: Bifurcation

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- We consider symmetric solutions:

$$F(W, \Sigma, \chi_N) = 0; \quad F : (L^p(V))^2 \times (0, \infty) \rightarrow (L^p(V))^2, \quad p \geq \frac{3}{2}$$

- Homogeneous solution:  $F(0, 0, \chi_N) = 0 \quad \forall \chi_N$

- Fréchet derivative:

$$F'(0, 0, \chi_N) = \begin{pmatrix} T_{11} & T_{12} \\ T_{21} & T_{22} \end{pmatrix},$$

where

$$T_{11} = 2\Delta^{-1} + 2\Delta^{-2} (I - e^\Delta),$$

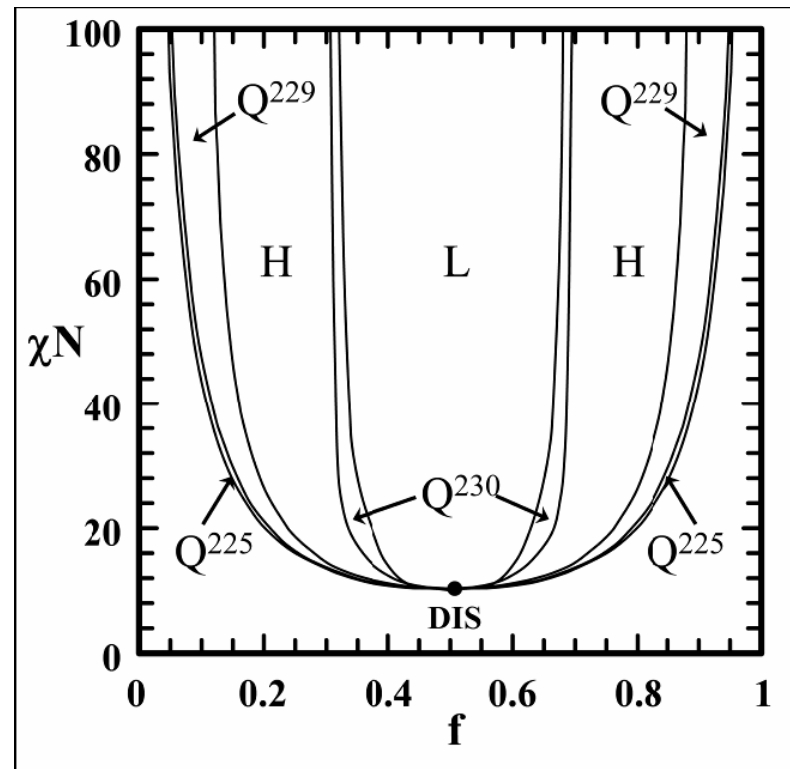
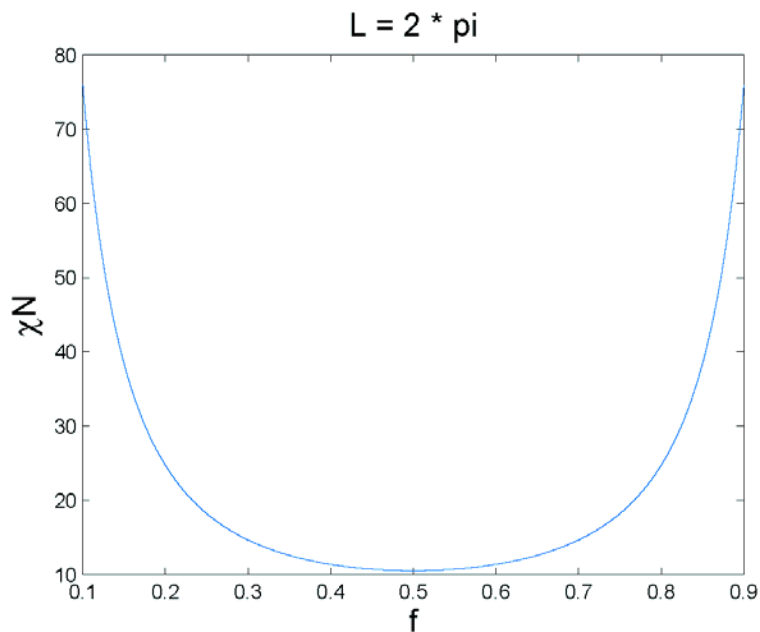
$$T_{12} = 2(1 - 2f)\Delta^{-1} + 2\Delta^{-2} (e^{f\Delta} - e^{(1-f)\Delta}),$$

$$T_{21} = -T_{12},$$

$$T_{22} = -2\Delta^{-1} - 2\Delta^{-2} (3I - 2e^{f\Delta} - 2e^{(1-f)\Delta} + e^\Delta) - \frac{2}{\chi_N}.$$

# Phase separation: Bifurcation (cont.)

- Crandall-Rabinowitz-type of bifurcation.



E.W. Cochran, CJGC, and G.H. Fredrickson, *Macromolecules*, 39(7), (2006).

# SCFT Equations: Numerics

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- Dynamics:
  - Mean field (saddle point) solution (SCFT)
  - Solving for Q and densities: most numerically expensive step.

$$\frac{\partial W}{\partial t} = \phi_A(x; W, \Sigma) - \phi_B(x; W, \Sigma) + 1 - 2f - \frac{1}{\chi_N} W,$$

$$\frac{\partial \Sigma}{\partial t} = \phi_A(x; W, \Sigma) + \phi_B(x; W, \Sigma) - 1,$$

$$\phi_A(x; W, \Sigma) = \frac{1}{Q} \int_0^f q(x, s) q^\dagger(x, 1 - s) ds,$$

$$\phi_B(x; W, \Sigma) = \frac{1}{Q} \int_f^1 q(x, s) q^\dagger(x, 1 - s) ds,$$

$$Q = \frac{1}{V} \int_V q(x, 1) dx.$$

# SCFT Equations: Challenges

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- Main ingredients:
  - Time-stepping of the chemical potentials.
  - Solver for modified diffusion equation.
  - Integration along the polymer chain.
- Nonlinear, nonlocal equations.
- Fully implicit: too costly.
- **Semi-Implicit Scheme via Linearization:**

$$\frac{W^{n+1} - W^n}{\Delta t} = \mathcal{L}[W^{n+1}] + F[W^n] - \mathcal{L}[W^n]$$

# Semi-Implicit Scheme for SCFT

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- Consider:  $\frac{\partial q}{\partial s} = \Delta q - \epsilon \omega q;$

- Asymptotic expansion (RPA):**

$$q(x, s) = 1 + \epsilon \sum_{k \neq 0} \hat{q}_1(k, s) e^{ikx} + O(\epsilon^2),$$

$$q^\dagger(x, s) = 1 + \epsilon \sum_{k \neq 0} \hat{q}_1^\dagger(k, s) e^{ikx} + O(\epsilon^2).$$

- Leading term in the density:**

$$\phi_A(x) = f + \epsilon \sum_{k \neq 0} e^{ikx} \int_0^f (\hat{q}_1(k, s) + \hat{q}_1^\dagger(k, 1 - s)) ds + O(\epsilon^2),$$

$$\phi_B(x) = 1 - f + \epsilon \sum_{k \neq 0} e^{ikx} \int_f^1 (\hat{q}_1(k, s) + \hat{q}_1^\dagger(k, 1 - s)) ds + O(\epsilon^2).$$

# Semi-Implicit Scheme for SCFT

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$$\begin{aligned}\frac{\Sigma^{n+1} - \Sigma^n}{\Delta t} &= -(g_{AA} + 2g_{AB} + g_{BB}) * \Sigma^{n+1} + (\phi_A^n + \phi_B^n - 1) \\ &\quad + (g_{AA} + 2g_{AB} + g_{BB}) * \Sigma^n, \\ \frac{W^{n+1} - W^n}{\Delta t} &= \phi_A^* - \phi_B^* + 1 - 2f - \frac{2}{\chi N} W^{n+1}.\end{aligned}$$

$$\begin{aligned}\hat{g}_{AA}(k) &= \frac{2}{|k|^4} \left( f|k|^2 + e^{-|k|^2 f} - 1 \right), \\ \hat{g}_{AB}(k) &= \frac{1}{|k|^4} \left( 1 - e^{-|k|^2 f} \right) \left( 1 - e^{-|k|^2 (1-f)} \right), \\ \hat{g}_{BB}(k) &= \frac{2}{|k|^4} \left( (1-f)|k|^2 + e^{-|k|^2 (1-f)} - 1 \right).\end{aligned}$$

**This scheme is unconditionally stable.**

# Modified Diffusion Equation

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$$\begin{aligned}\frac{\partial q}{\partial s} &= \Delta q - \psi q, & x \in V, & s \in (0, 1), \\ q(x, 0) &= 1,\end{aligned}$$

**Operator Splitting (2<sup>nd</sup> order):**

$$q_{n+1} = e^{-\frac{\psi \Delta s}{2}} e^{\Delta s \Delta} e^{-\frac{\psi \Delta s}{2}} q_n$$

G. Strang, *Numerische Mathematik*, 6, 1964

K. O. Rasmussen and G. Kalosakas, *Journal of Polymer Science B: Polymer Physics*, 2002, 40, 1777

# Solving the Modified Diffusion Equation

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**Modified Diffusion Equation:**  $\frac{\partial q}{\partial s} = \Delta q - \psi q$

**Fourth Order BDF, initialized with Backward Euler + Extrapolation:**

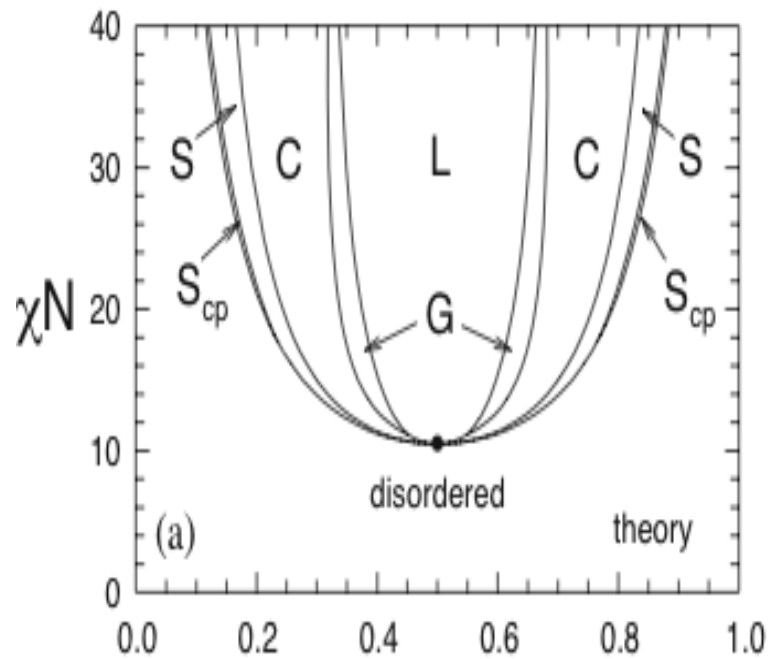
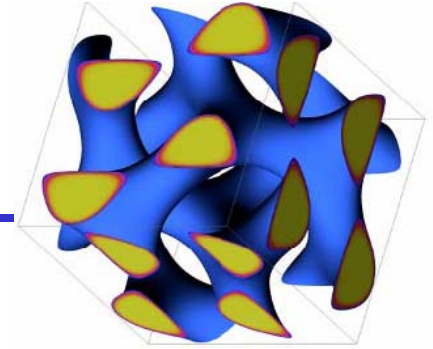
$$\frac{25}{12}q_{n+1} = 4q_n - 3q_{n-1} + \frac{4}{3}q_{n-2} - \frac{1}{4}q_{n-3} + \Delta s[\Delta q_{n+1} - w(u)(4q_n - 6q_{n-1} + 4q_{n-2} - q_{n-3})]$$

**Trapezoidal rule with endpoint corrections:**

$$\int_I f ds = \Delta x \sum_{i=0}^{m'} f_i - \frac{\Delta s^2}{12} \left( \frac{3f_m - 4f_{m-1} + f_{m-2}}{2\Delta s} - \frac{3f_0 - 4f_1 + f_2}{2\Delta s} \right) + O(\Delta s^4)$$

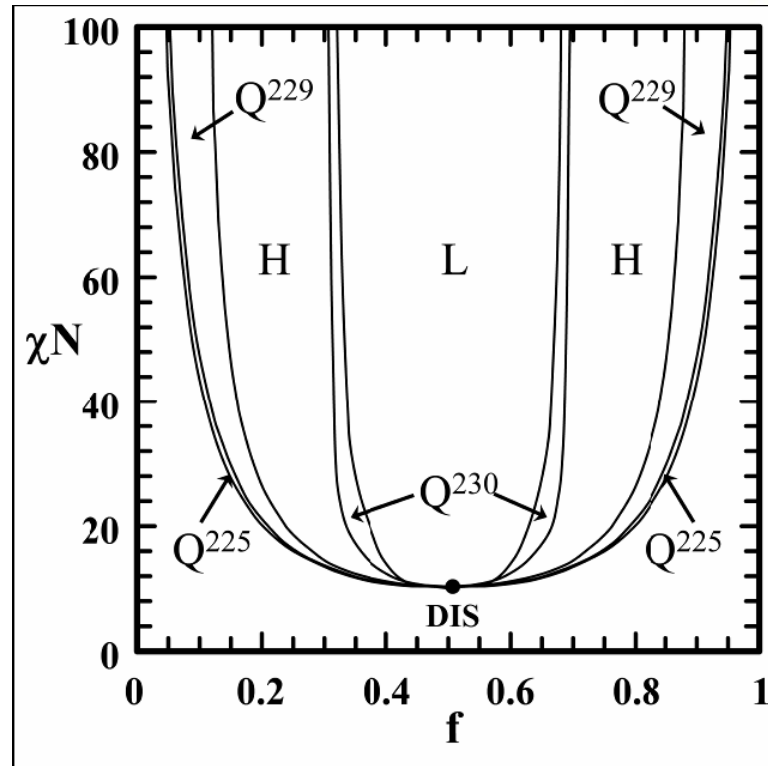
E.W. Cochran, CJGC, and G.H. Fredrickson, *Macromolecules*, 39(7), pp. 2449-2451 (2006)

# Stability of the gyroid phase



Matsen, M.W.; Schick, M.; *PRL*, 72(16) (1994).

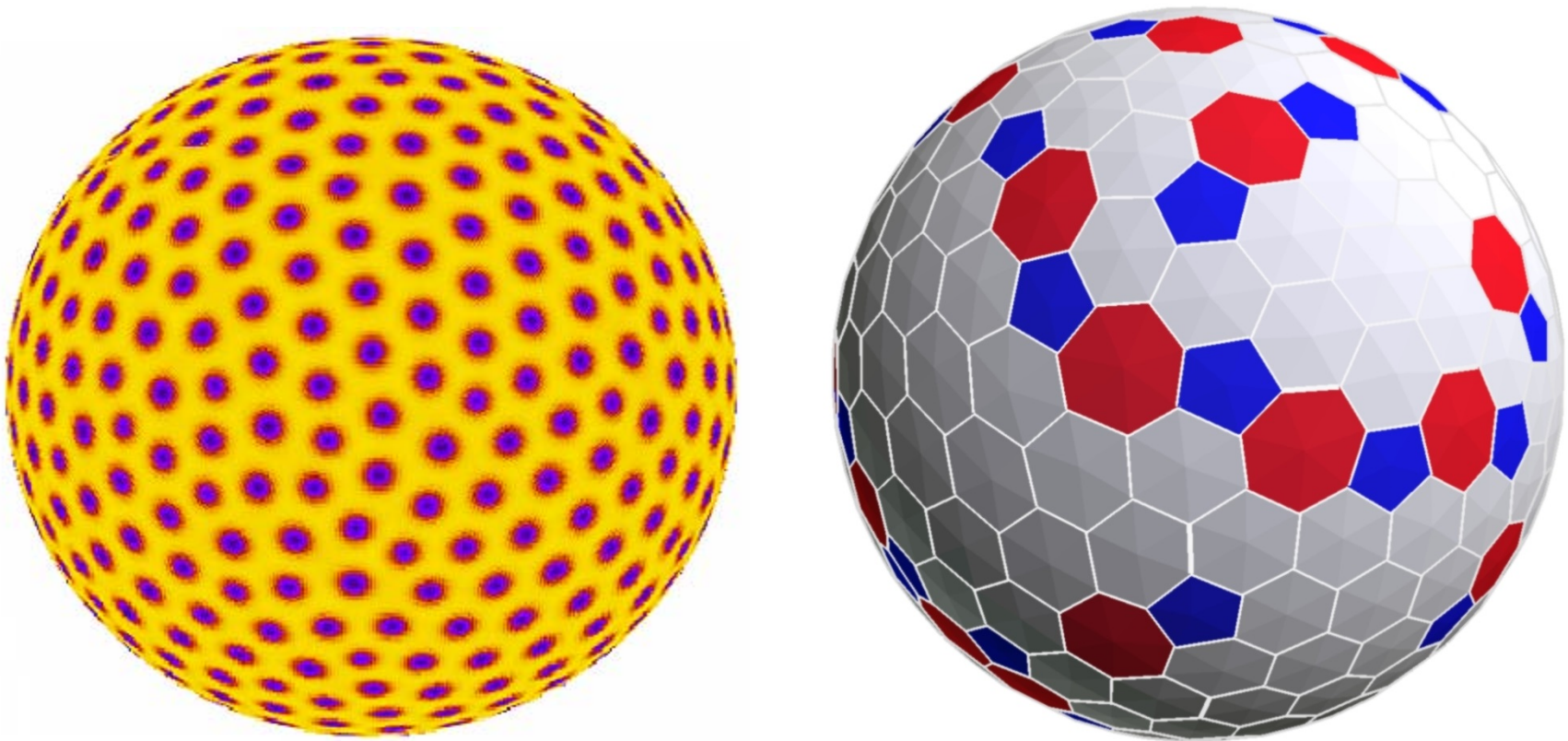
Matsen, M. W.; Bates, F. S. *Macromolecules* 29, (1996).



E.W. Cochran, CJGC, and G.H. Fredrickson, *Macromolecules*, 39(7), (2006).

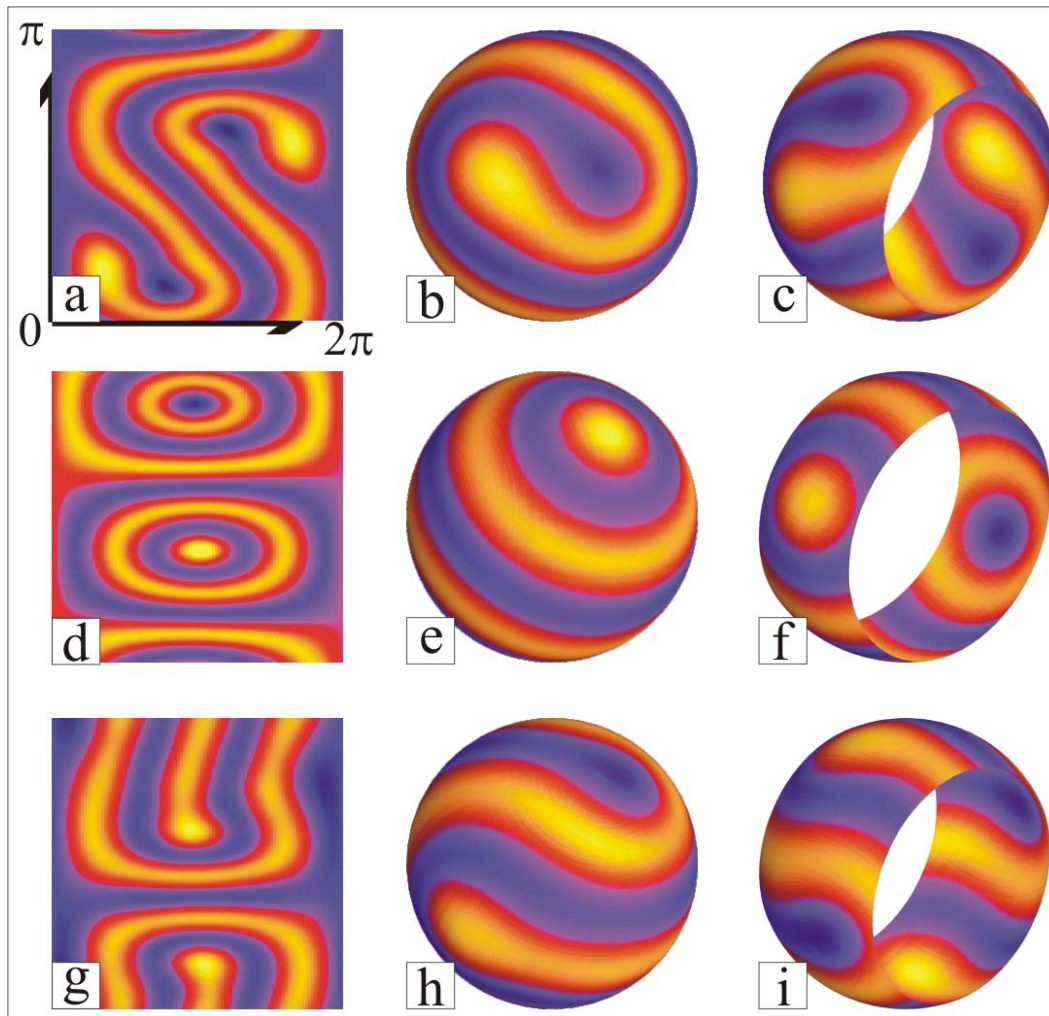
# Block-Copolymers on Curved Surfaces

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**Total of 446 domains:  
69 (5-fold) , 350 (6-fold) , and 57 (7-fold)**

# Lamellar phase



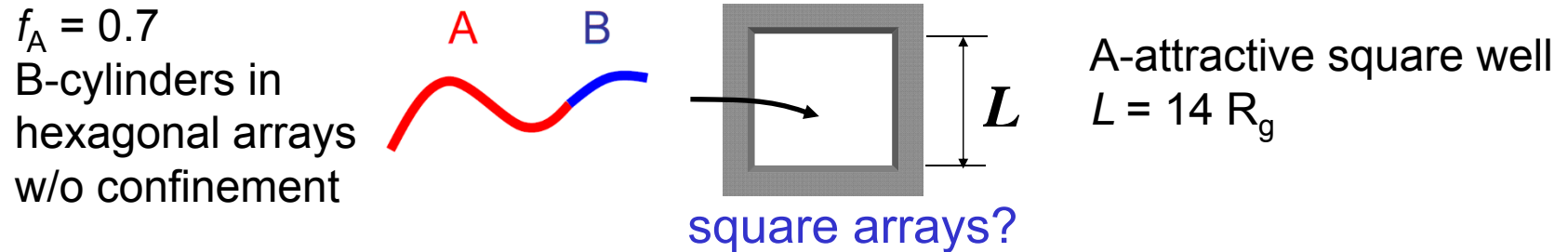
**Spiral**

**Hedgehog**

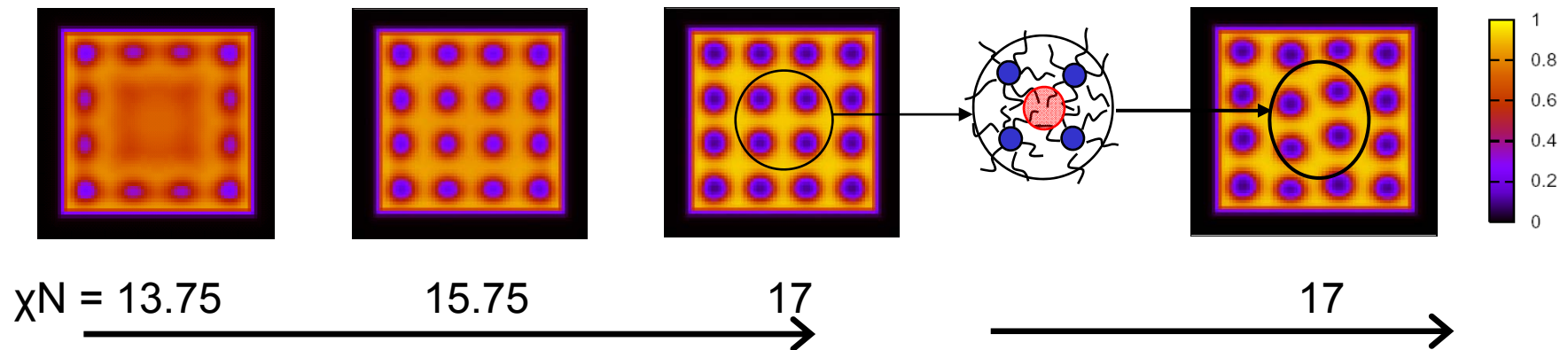
**Quasibaseball**

T.L. Chantawansri, A.W. Bosse, A. Hexemer, H.D. Cenicerros, C.J. García-Cervera, E.J. Kramer, and G.H. Fredrickson,  
*Phys. Rev. E*, 75(3), 031802 (2007)

# Lithography: AB in a Square Well



Representative (normalized) density profiles of A-segment



Tetragonal ordering is induced by the square lateral confinement during annealing stage.

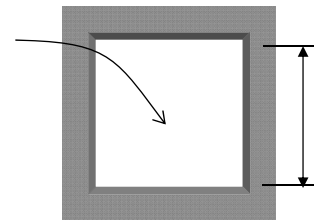
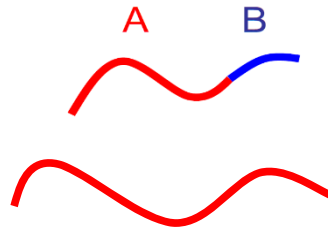
Lattice subsequently twists into hexagonal ordering in order to reduce the stress in the interstitial sites.

# AB + A in a Square Well

- A-homopolymer additive stabilizes tetragonal ordering

$$f_A = 0.7$$

B-cylinder forming diblock



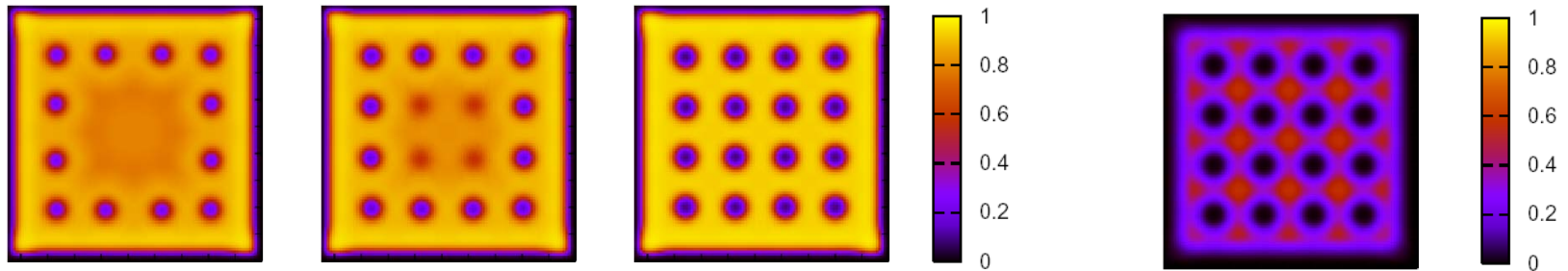
$$L = 23 R_g$$

B-attractive wall

$$\alpha = 1.75 \quad (N_{Ah}/N)$$

$$V_{Ah} = 0.23$$

A(major block)-homopolymer



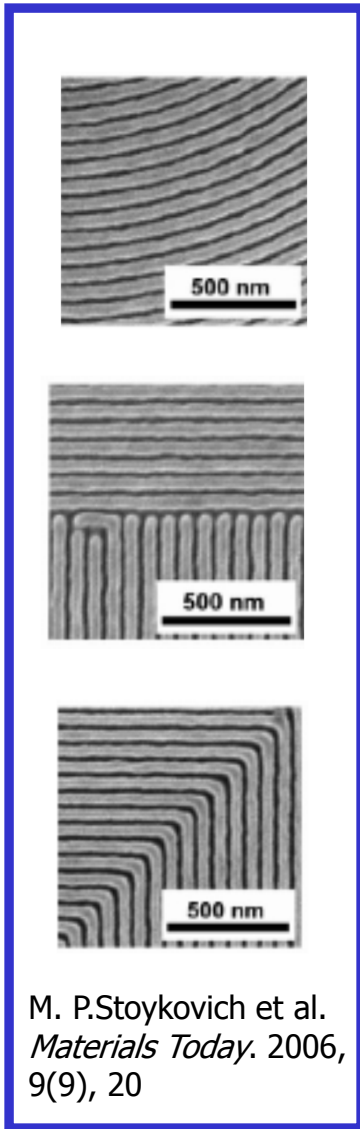
Evolution of total A-segment

A-homopolymer  
segment concentration

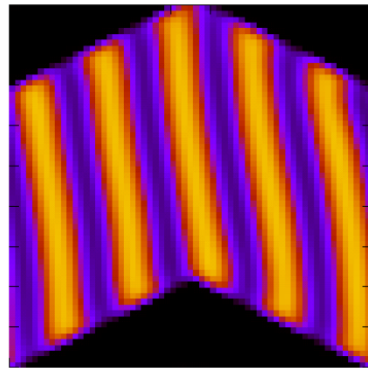
A-homopolymer localization decreases the free energy of the square configuration such that it is energetically more favorable than the hexagonal configuration.

# Bent Lines : AB + A + Confinement

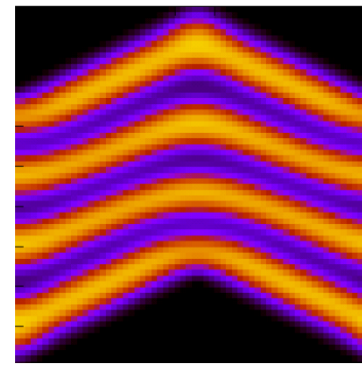
$$f_A = 0.5, \text{ Channel Width} = 9 R_g$$



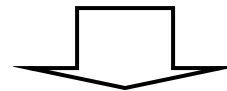
AB + neutral wall



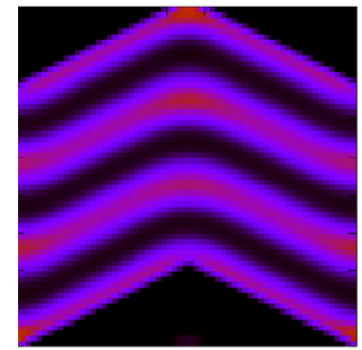
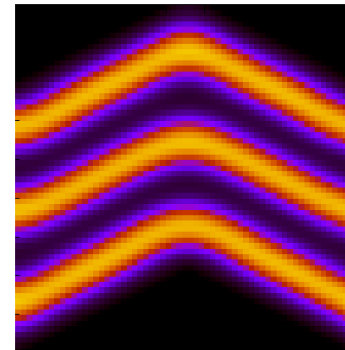
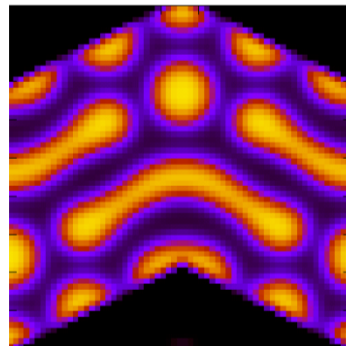
AB + A-attractive wall



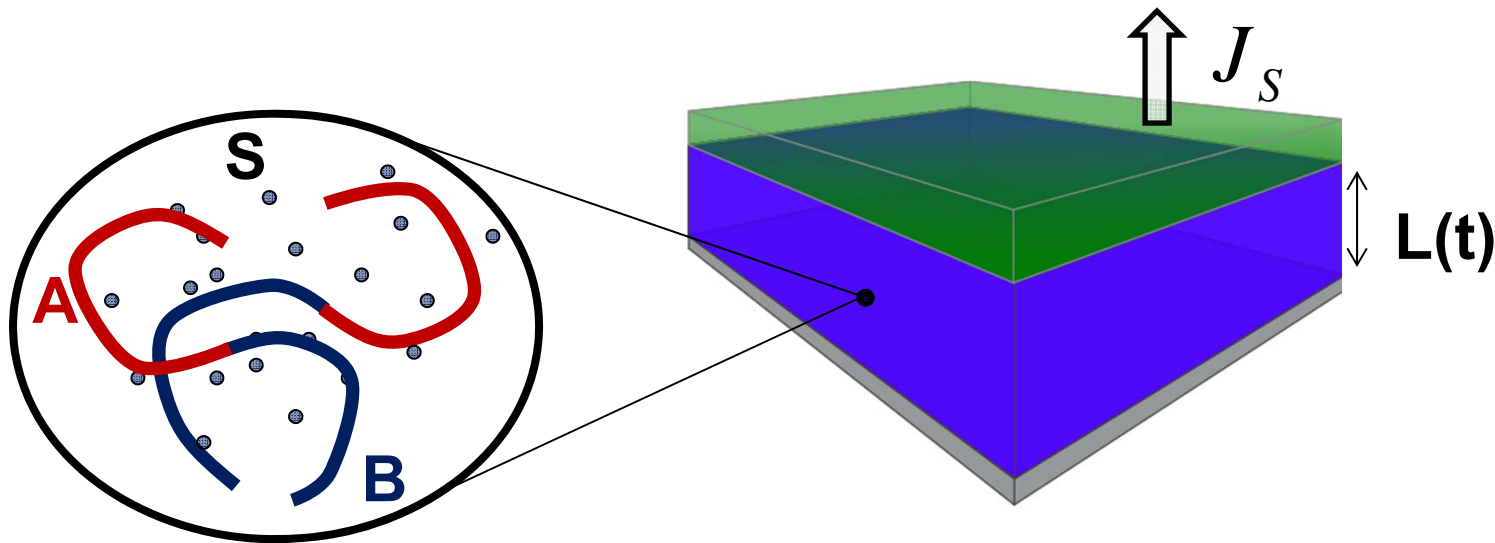
$$\sim 12.7 R_g$$



+ A ( $\alpha = 0.5 (N_{Ah}/N)$ ,  $V_{Ah} = 0.2$ )



# Dynamical Self-Consistent Field Theory



$$\partial_t \phi_K = \nabla \cdot M_K \nabla \mu_K^{SCFT} + J_S \delta_{KS}$$

$$K = \{A, B, S\}$$

**Density flux from SCFT free energy**  
**Solvent removal from surface of film**

# SCFT Free Energy

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Free energy  $\implies$  Legendre Transform of  $H[w]$

$$F[\rho] = \sup_w \left\{ \int_V \rho w - H[w] \right\}$$

$\Downarrow$

$$\rho(\mathbf{x}) = \phi(\mathbf{x}; w^*) \quad (\text{Feynman} - \text{Kac})$$

**Nonlinear, Nonlocal equation**

# Chemical Potential: SCFT Free Energy

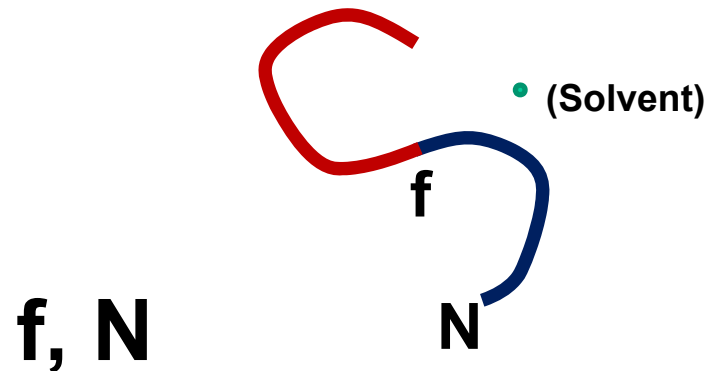
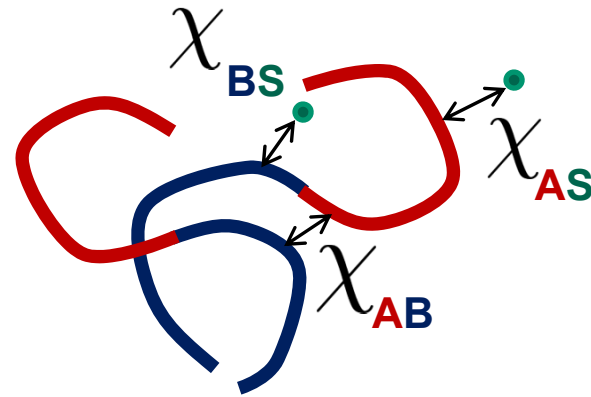
---

$$\mu(r, t)_K^{SCFT} = \left. \frac{\delta H}{\delta \phi(r, t)_K} \right|_{\underline{w}^*}$$
$$= C \left( \sum_J \chi_{KJ} \phi(r, t)_J - \boxed{w(r, t)_K^*} + \zeta \left( \left( \sum_J \phi(r, t)_J \right) - 1 \right) \right)$$

$$\hat{\phi}_K(r; \underline{w}^*) = \int q(r, s; \underline{w}^*) q'(r, s; \underline{w}^*) ds = \phi_K(r, t)$$

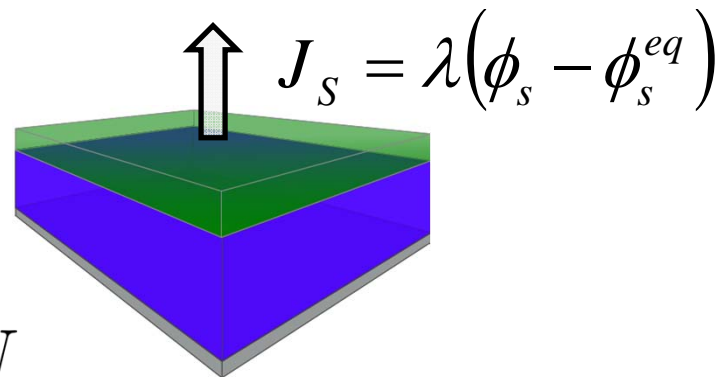
# Parameters Involved In Our Study

$$\chi_{AB} \quad \chi_{AS} \quad \chi_{BS}$$



$$\phi_S^{eq}$$

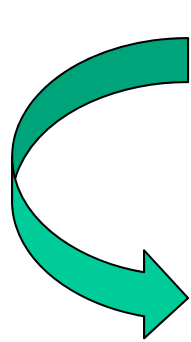
$$\chi_{AB}^{eff} N = (1 - \phi_S^{eq}) \chi_{AB} N$$



# Moving Boundary Model

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$$\partial_{\bar{t}} \phi_K = \nabla \cdot M_K \nabla \mu_K^{SCFT} + J_S \delta_{KS}$$



$$\bar{z} = \frac{z}{L(t)}$$

$$\left( \frac{\partial \phi}{\partial t} \right)_{\bar{z}} = \left( \frac{\partial \phi}{\partial t} \right)_z + \left( \frac{\partial \phi}{\partial z} \right)_t \left( \frac{\partial z}{\partial t} \right)_{\bar{z}}$$

$$= \nabla \cdot M \nabla \mu^{SCFT} + \bar{z} L'(t) \left( \frac{\partial \phi}{\partial z} \right)_t$$

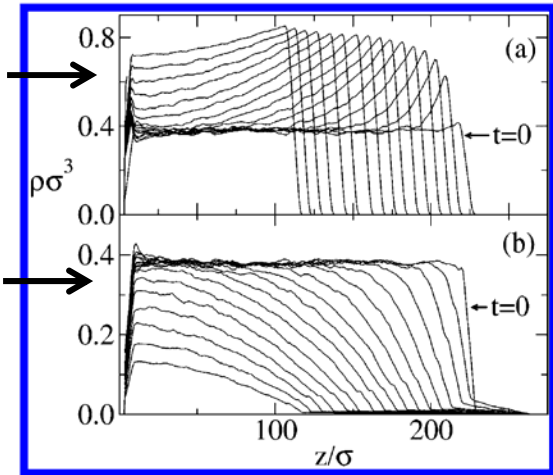
# Verification of Continuum Dynamics

## MD Simulation Details:

- 6-12 LJ Fluid
- FENE bonds
- Strong 10-4 LJ interaction with  $z=0$  surface prevents a 'floating' film

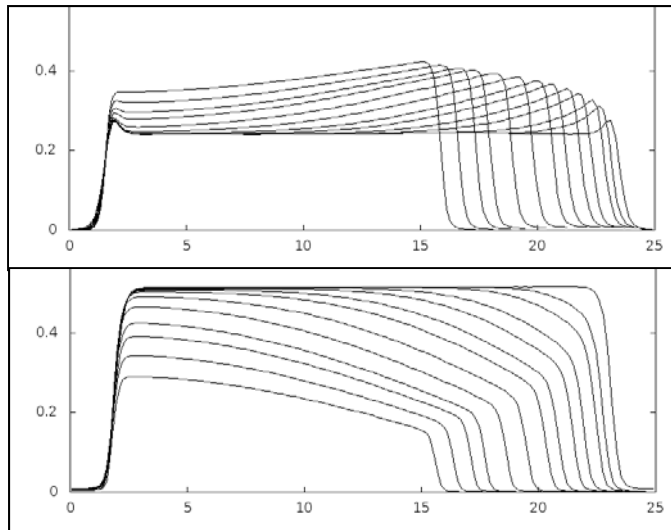
Polymer

Solvent

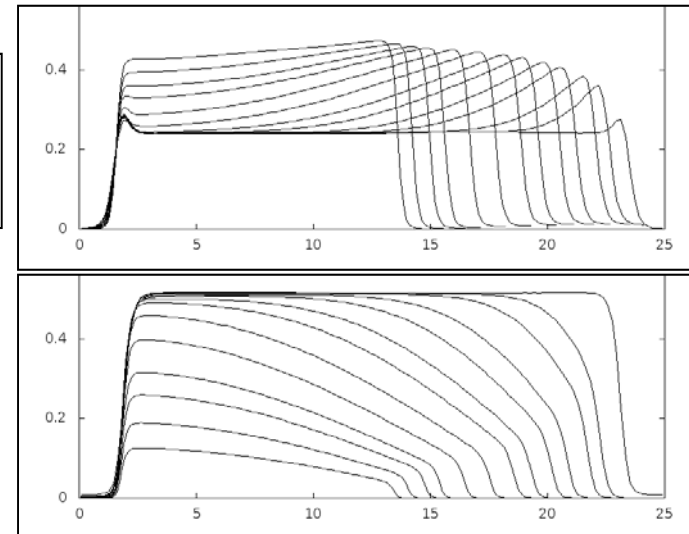


## Typical Moving Boundary Model Profiles:

$N=10$   
 $K=-1.0$   
 $XN_{\text{Surf}}=3.3$



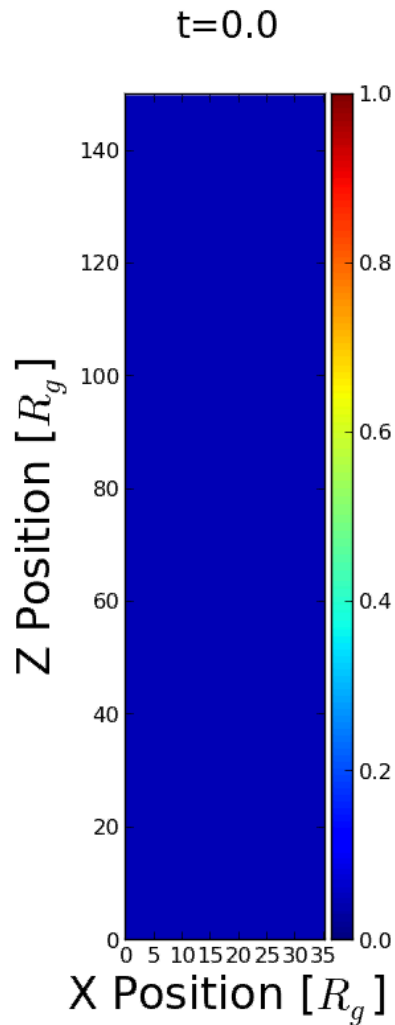
$N=10$   
 $K=-7.0$   
 $XN_{\text{Surf}}=3.3$



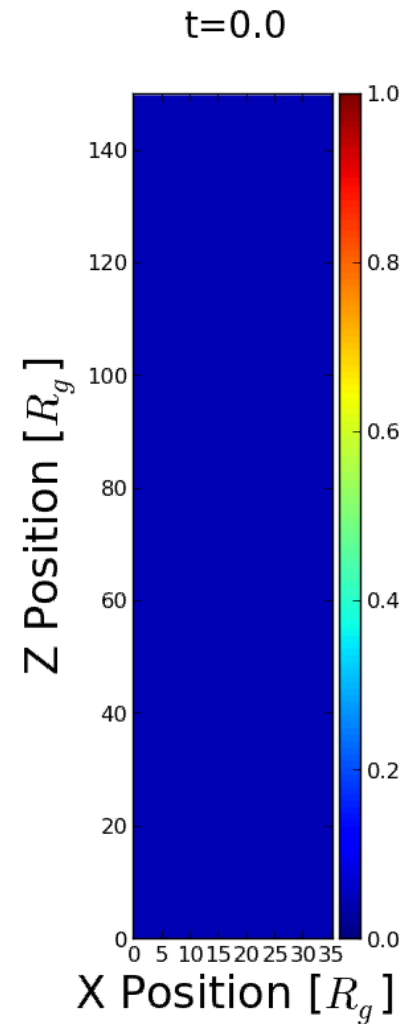
1. Tsige, M. Molecular dynamics study of the evaporation process in polymer films. *Macromolecules* 19, 1405 (2004).

# Evaporation Dynamics in 2D: Lamellae

$$\begin{aligned}\chi_{AB}N &= 22 \\ f_{\text{BCP}} &= 0.5 \\ \phi_S^{eq} &= 0.3\end{aligned}$$

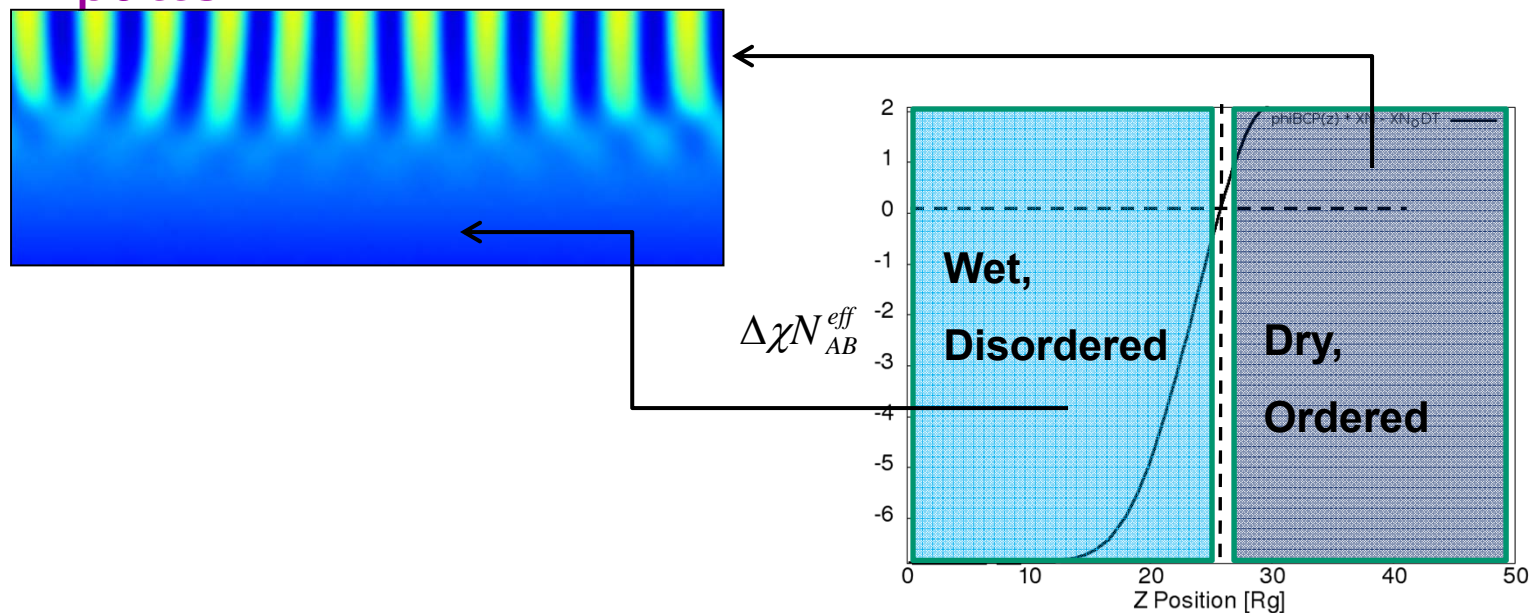


$$\begin{aligned}\chi_{AB}N &= 22 \\ f_{\text{BCP}} &= 0.5 \\ \phi_S^{eq} &= 0.18\end{aligned}$$



# Morphology Guided by Secondary Patterns

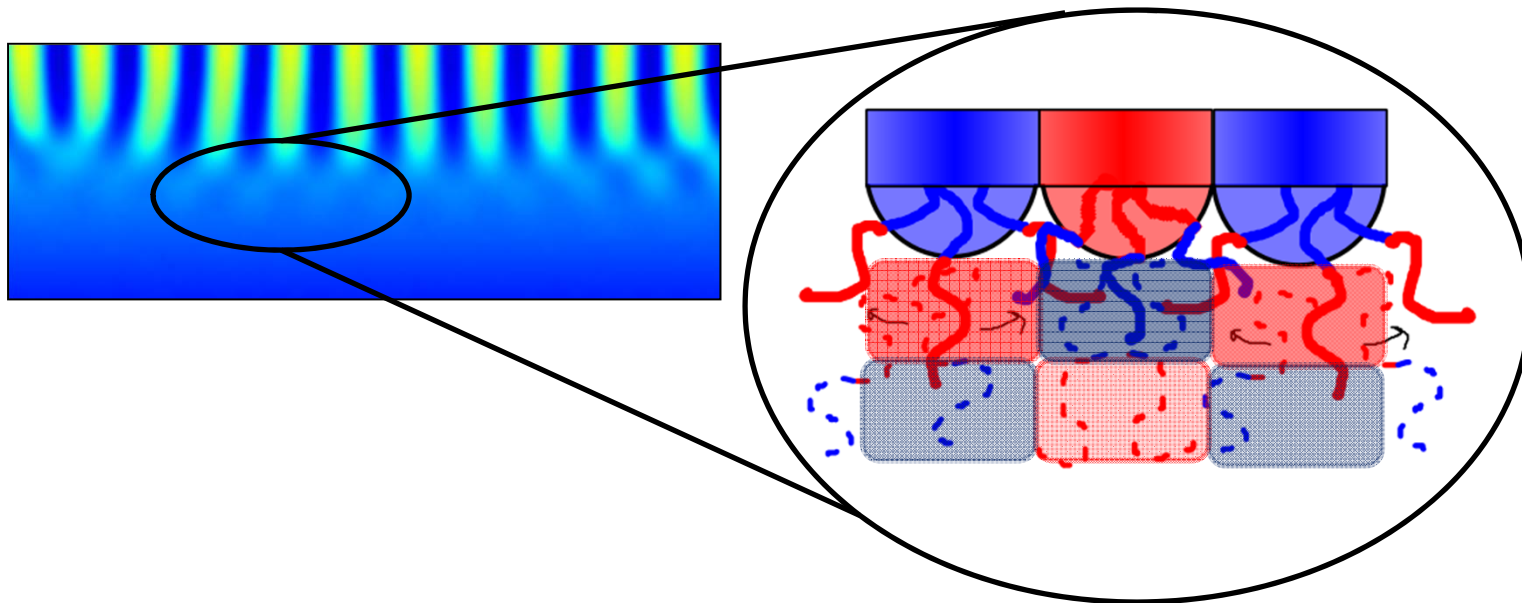
- Ordered phase induces density correlations in near-critical fluid beneath it.
  - Every dynamical result exhibits some form of this pattern



# Molecular Origin of Induced Patterns

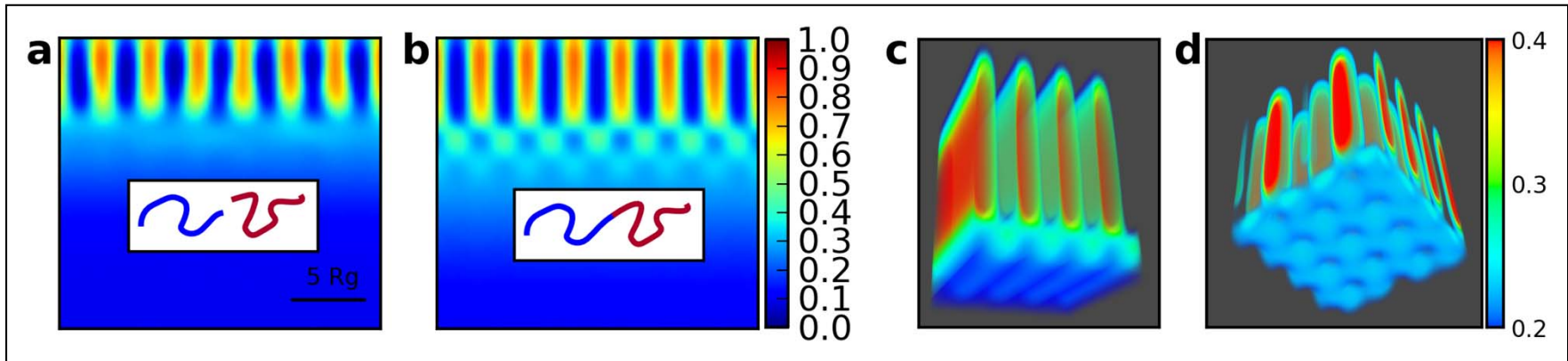
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- Block connectivity
  - Stripes terminate in dangling chain ends of the **opposite type**
  - Results in an increase in the **probability of finding B segments beneath A-rich Lamellae**



# Control Experiments

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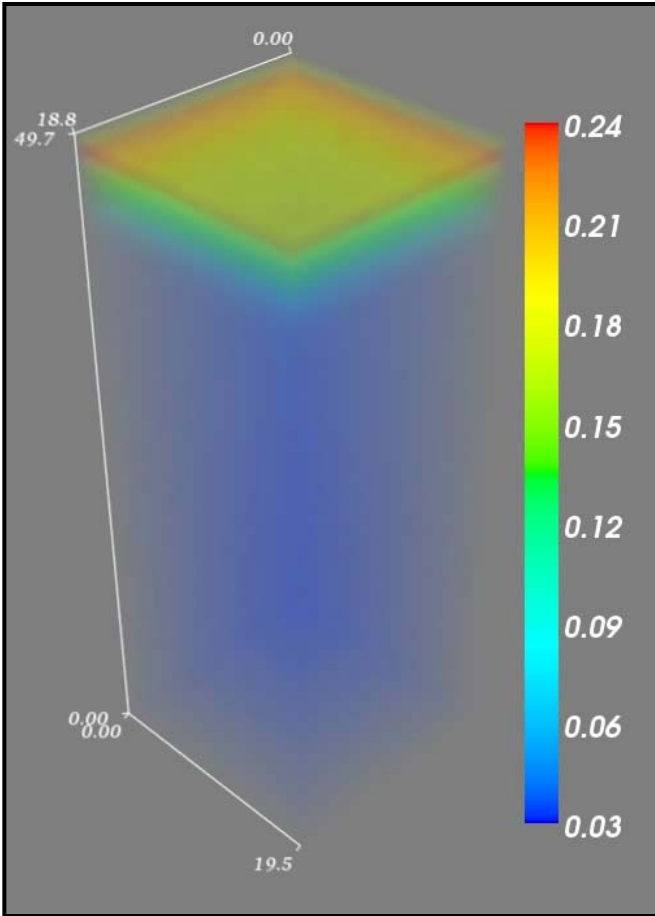
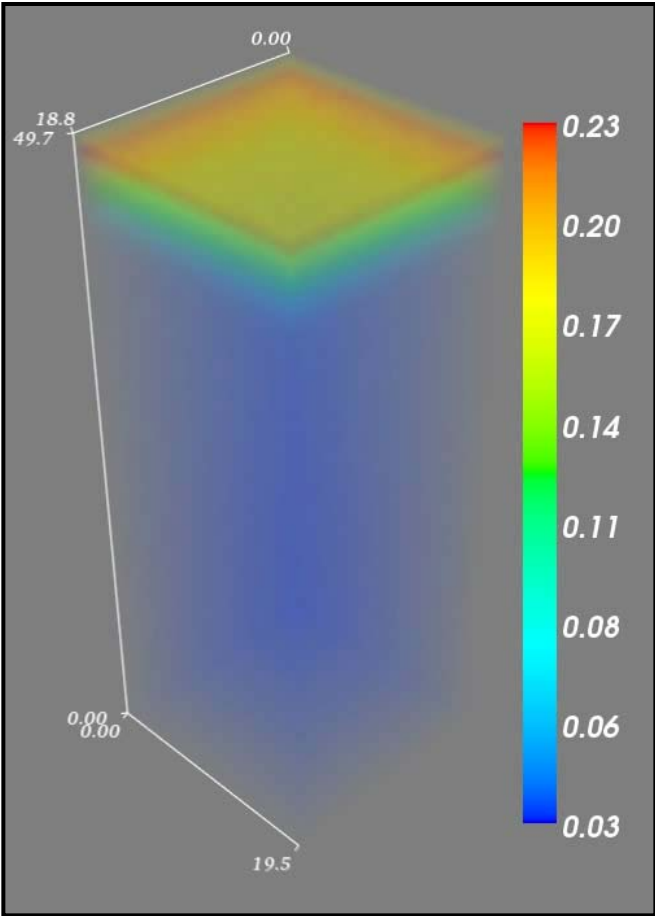


Evaporation simulations on a symmetric blend (a) and diblock (b) system implicate chain connectivity in patterning at the front.

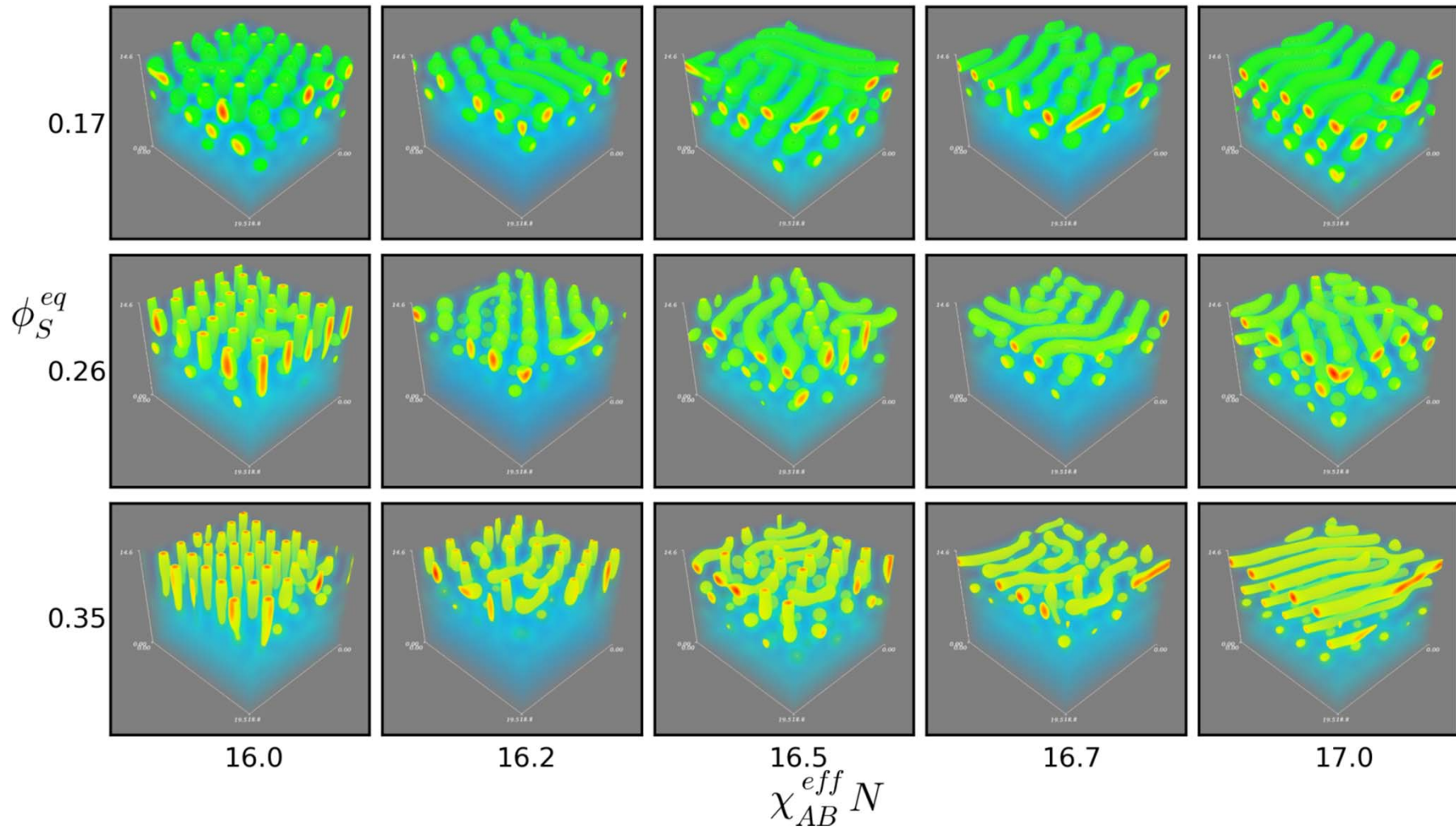
Cylinder-forming systems (d) emerge a pattern analogous to the “struts” in (b) and (c)

# Evaporation Trajectories

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# Trends in Surface Morphology

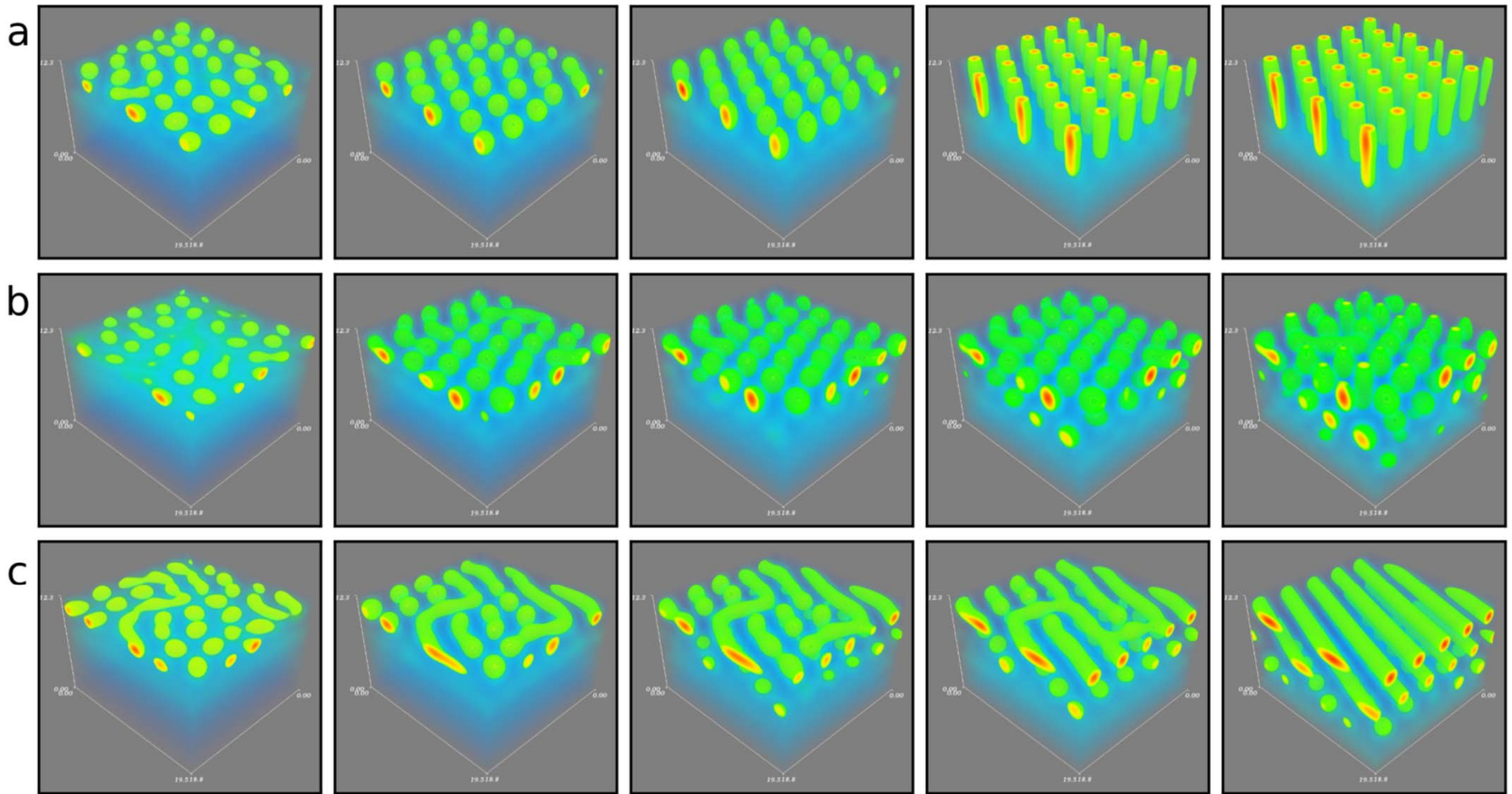


# Trends in Surface Morphology

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- Parameters  $\phi_S^{\text{eq}}$  and  $\chi_{AB}^{\text{eff}}$  are changed independently.
- $\chi_{AB}^{\text{eff}}$  increased: morphologies transition from perpendicular to horizontal.
- Changes in evaporation rate have minor effect.

# Evaporation-driven Ordering



Time

# Evaporation-driven Ordering

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- No order observed until unstable region near the surface forms: A layer of spheres appears.
- Spheres organize into a hexagonal lattice.
- A bifurcation occurs: For high  $\chi_{AB}^{\text{eff}}$ , spheres are unstable as seen in phase diagram.
- Lower values of  $\chi_{AB}^{\text{eff}}$  or slower evaporation rates provide sufficient time for solvent gradients to advance, and spheres to stretch.



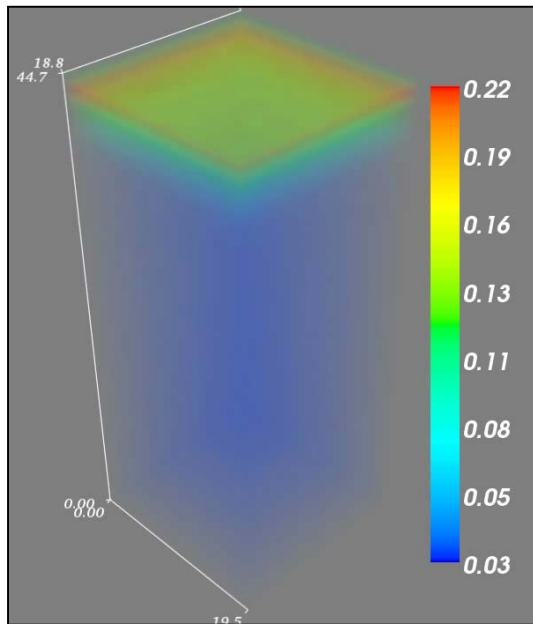
# Mitigating the Correlation-Hole

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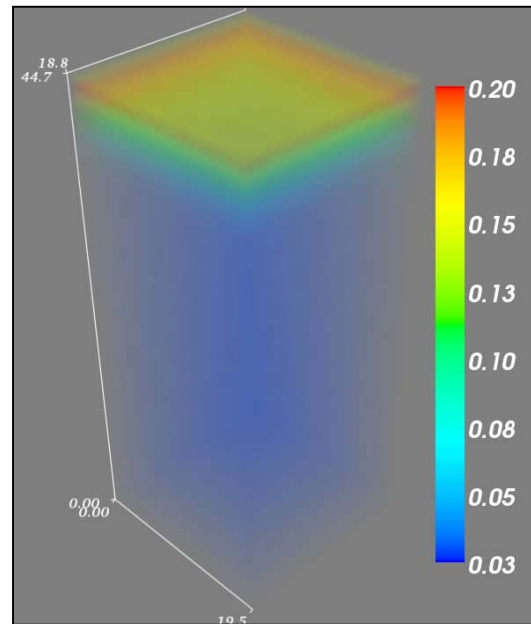
- The correlation-hole pattern that forms beneath  $C_{\perp}$  presents an increased density of minority-block segments.
- Hypothesis: solvent selective for majority block will provide a barrier to forming this pattern and stabilize  $C_{\perp}$  fronts

# Selective Solvent Results

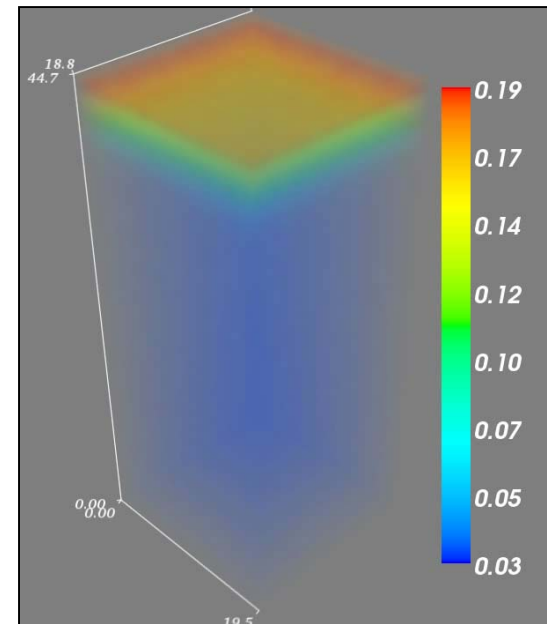
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**Minority-Selective**



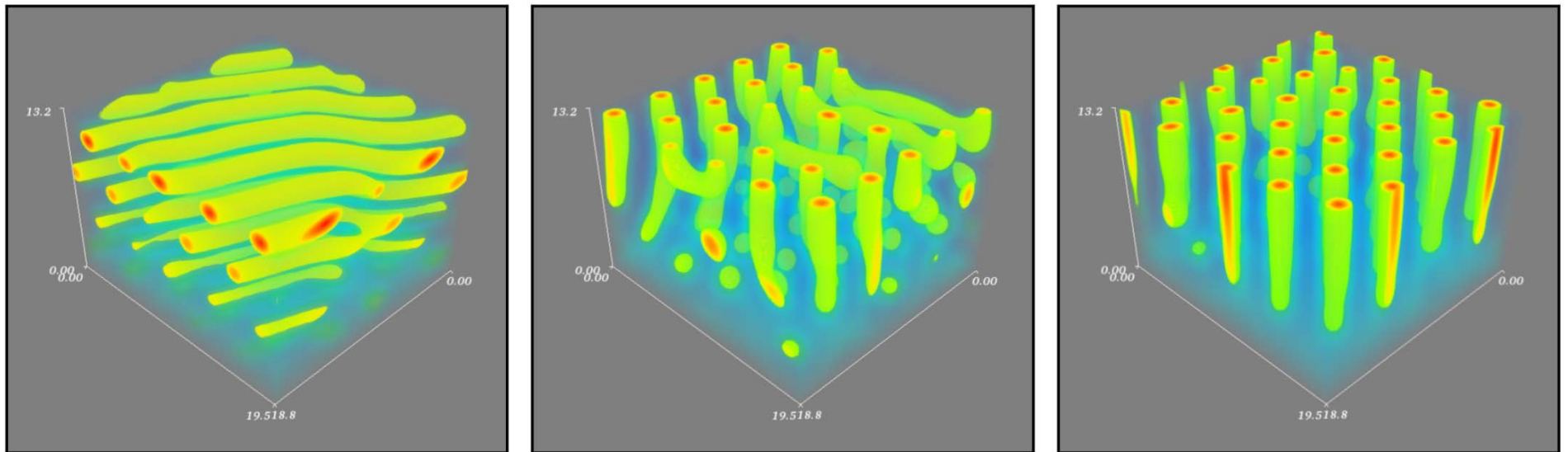
**Neutral**



**Majority-Selective**

# Selective Solvent Stabilizes Cylinder Formation

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Increasing Solvent Selectivity

# Overview and Future Work

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- Developed efficient predictive numerical methodologies.
- Numerical experiments guide design of lithographic approaches and elucidate evaporation-induced pattern selection
  
- Further understanding of evaporation processes needed.
- Hydrodynamics: Coupling to Navier-Stokes?.
- Dynamic density functional theory: Can we invert the density?  $\rho_0 = \rho(x; W, \Sigma) \rightarrow$  Can we recover  $W$  and  $\Sigma$ ?
- Framework too complicated: Can we obtain reduced models?

\*C.B. Muratov, M. Novaga, G. Orlandi, and CJGC in *"Singularities in nonlinear evolution phenomena and applications"*, CRM Series, 9, Birkhauser, (2009).

# Acknowledgments

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